## INVITED

## Improvement of Critical Current Densities of MgB<sub>2</sub> Tapes and Wires

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Impurity addition is an effective method to improve  $J_c$  of MgB<sub>2</sub> wires and tapes, and many impurity additions are now being tried out in the world. Among many kinds of impurities, additions of carbon compounds such as nano-SiC and hydrocarbon are particularly effective. We found that the additions of ethyltoluene( $C_9H_{12}$ ) to the starting powder of *in situ* processed Powder-In-Tube(PIT) MgB<sub>2</sub>/Fe tapes is more effective in enhancing  $J_c$  value than other hydrocarbon additions in spite of smaller amount of carbon substitution for boron site. The slope of  $J_c$ -B curve of ethyltoluene-added tape is almost equal to that of pure MgB<sub>2</sub> tape. These results suggest that the dominant mechanism of  $J_c$  enhancement for ethyltoluene-added tape is different from carbon substitution for boron. The analysis by the Rowell's method indicates that the connectivity of  $MgB_2$  is improved by the ethyltoluene addition. The addition of both ethyltoluene and SiC nano powder to the starting powder is much more effective in increasing  $J_c$  values. This is because both mechanisms of  $J_c$  improvement--one comes from the addition of ethyltoluene, and the other comes from the carbon substitution for boron by the SiC addition--work together. The highest  $J_c$  values at 4.2K reached 32,000A/cm<sup>2</sup> in 10T and 14,000A/cm<sup>2</sup> in 12T for 10mol% ethyltoluene and 10mol%SiC-added tape. However, these  $J_c$  values are still below the practical level due to the low density of MgB<sub>2</sub> cores. Recently, we succeeded in the fabrication of MgB<sub>2</sub>/Fe wires having high density MgB<sub>2</sub> core applying the internal Mg diffusion (IMD) process with pure Mg rod and pure B powder or nano-SiC added B powders. A pure Mg rod with a diameter of 2 mm was placed at the center of a Fe tube with an outer diameter of 6mm and inner diameter of 3.5 mm, and space between the Mg rod and the Fe tube was filled with B powder or B-SiC mixed powder. The composite was successfully cold worked into  $0.8 \sim 1.2$  mm wire at room temperature without any breakage. The wires were heat treated at  $650 \sim 800$  °C for  $1 \sim 10$  hrs under Ar gas atmosphere. During the heat treatment, liquid Mg infiltrated into the B layer and reacted with B to form MgB<sub>2</sub>. X-ray diffraction analysis indicated that the major phase in the reacted layer is MgB<sub>2</sub>. SEM analysis of the heat treated wire clearly indicated that the density of MgB<sub>2</sub> layer in the wire was higher than that of a PIT processed wire. The  $J_c$  at 4.2K of the IMD-processed wire increased with decreasing the heat treatment temperature from 800 °C. Transport  $J_c$  values of the SiC added wire heat treated at 670°C reached 1.1 x 10<sup>5</sup>A/cm<sup>2</sup> in 8T and 43,000 A/cm<sup>2</sup> in 10T at 4.2K. These  $J_c$  values are much higher than those of usual PIT processed wires. These high  $J_c$  values can be attributed to the high density MgB<sub>2</sub> layer obtained by this diffusion method. Thus, the densification of MgB<sub>2</sub> layer is effective in enhancing  $J_c$  of MgB<sub>2</sub> wires.

Keywords: impurity addition, ethyltoluene, critical current density, diffusion method

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